

ECE 5205 HW#3 2-20-2014 Total 20 points turn in 2-27-2014

1. **MOS Capacitor.** In the lecture, equation (1) (see 2nd page) has been derived for the semiconductor charge. Show that in accumulation and strong inversion the charge Q_s increases as $\exp(\psi/2kT)$. (3 points)
2. **MOS Capacitor.** Assume a p-type substrate with uniform boron doping of $1 \times 10^{16} \text{ cm}^{-3}$. Using the formula (2) (see 2nd page) derived in the lecture, calculate the Si capacitance for surface potentials $\psi = -0.21\text{V}$ and 0.85V . (4 points)
3. **MOS Capacitor.** The work function for aluminum is 4.10V ; the electron affinity for Si is 4.05V . Assume a p-type doping level of $1 \times 10^{14} \text{ cm}^{-3}$. Calculate the flat band voltage assuming that there are no oxide charges of any kind. (2 points)
4. **Flat Band Voltage:** Calculate flat band voltage for MOS capacitor with a p-type semiconductor substrate of $1 \times 10^{16} \text{ cm}^{-3}$, SiO₂ thickness of 200\AA and n+polysilicon gate. Assume that you have trapped charge $Q_{ss} = 5 \times 10^{10} \text{ cm}^{-2}$ located directly adjacent to the oxide-Si interface. (2 points)
5. **Threshold Voltage:** Design the oxide thickness of an MOS system to yield a specified threshold voltage of $V_T = 0.65\text{V}$. Consider an N+ polysilicon gate and a p-type substrate of $3 \times 10^{16} \text{ cm}^{-3}$ and assume $Q_{ss} = 10^{11} \text{ cm}^{-2}$. (4 points)
6. **CV characteristics of a MOS capacitor.** Consider a p-type substrate of $1 \times 10^{16} \text{ cm}^{-3}$, an oxide thickness of 550\AA and an aluminum gate. Calculate C_{ox} , C_{min} (for maximum depletion) and C_{FB} (flat band capacitance of the entire MOS capacitance system). (5 points)

$$Q_s = -\epsilon_s E_s = \pm \frac{\epsilon_s \sqrt{2}}{\beta L_D} F\left(\beta \psi_s, \frac{n_{po}}{p_{po}}\right)$$

Eq. (1) Si charge as a function of the surface potential, see lecture notes

$$C_D \equiv \frac{\partial Q_s}{\partial \psi_s} = \frac{\epsilon_s}{\sqrt{2} L_D} \frac{[1 - (\exp(-\beta \psi_s) + \frac{n_{po}}{p_{po}} (\exp(\beta \psi_s) - 1))]}{F(\beta \psi_s, \frac{n_{po}}{p_{po}})}$$

Eq. (2) Differential capacitance of the depletion layer, see lecture notes